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Sommario/riassunto

This book, authored by Franklin Tao, explores the application of Ambient Pressure X-ray Photoelectron Spectroscopy (AP-XPS) in the study of catalysts. It delves into the principles and techniques of XPS, highlighting its significance in analyzing catalyst surfaces under various environmental conditions, including gaseous phases. The text discusses the challenges and methodologies involved in studying catalytic reactions and offers insights into the technical aspects of AP-XPS, such as energy analysis and reaction cell design. Intended for researchers and professionals in chemical engineering and catalysis, the book provides an in-depth examination of surface phenomena and the role of AP-XPS in advancing the understanding of catalytic processes.
